



WHITING SCHOOL of Engineering

Bacterial Sequencing and Assembly for Analysis of Antibiotic Resistance Genes and Mutations

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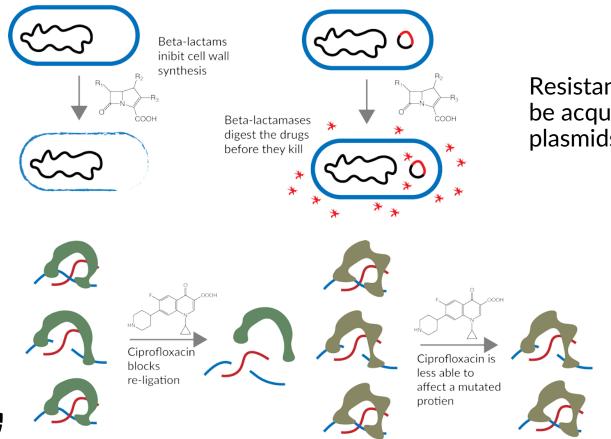
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Timp Lab

Sequencing, Finishing and Analysis in the Future May 24, 2018

Antimicrobial Resistance



Resistance genes can be acquired via plasmids.

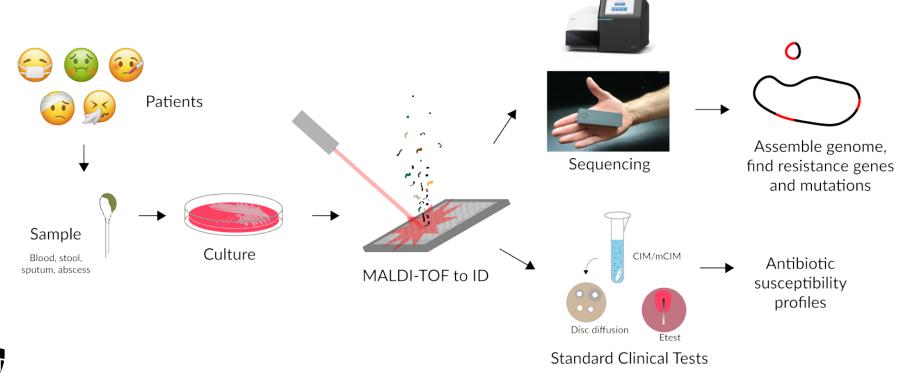
> Mutations of otherwise benign genes can confer resistance.

(gyrA)

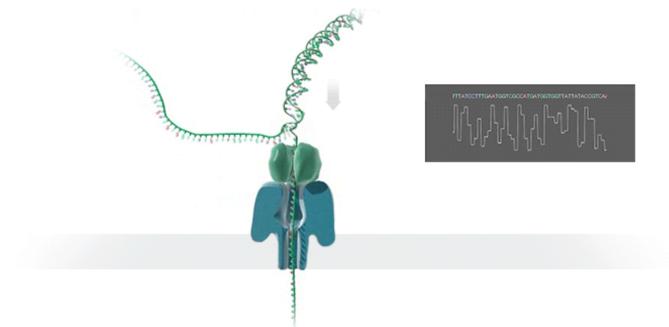
Aldred et al *Biochemistry* (Feb 2014)

Overview

Associate resistance phenotypes with genetic features.



Nanopore Sequencing



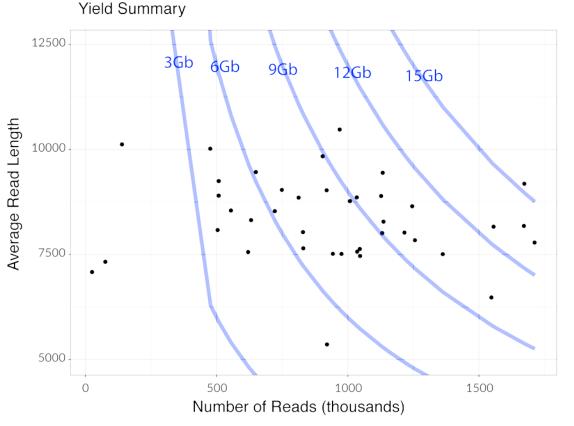
Changes in ionic current are measured as DNA threads through a pore.

Multiple bases occupy the pore at once – these k-mers produce characteristic current signatures.



Oxford Nanopore Technologies

Nanopore Sequencing



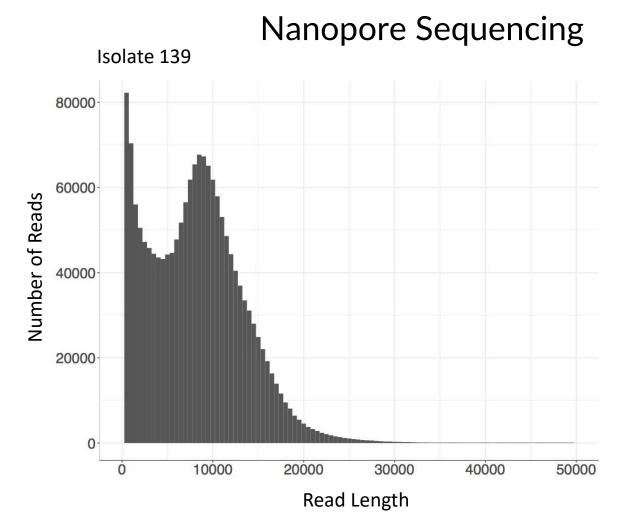
We easily get long reads and high coverage – both critical for good assemblies.

Simner Lab bacterial runs average 8.9Gb in yield. At \$500 per flowcell, it costs less than 50 cents for 1X coverage of a large bacterial genome.

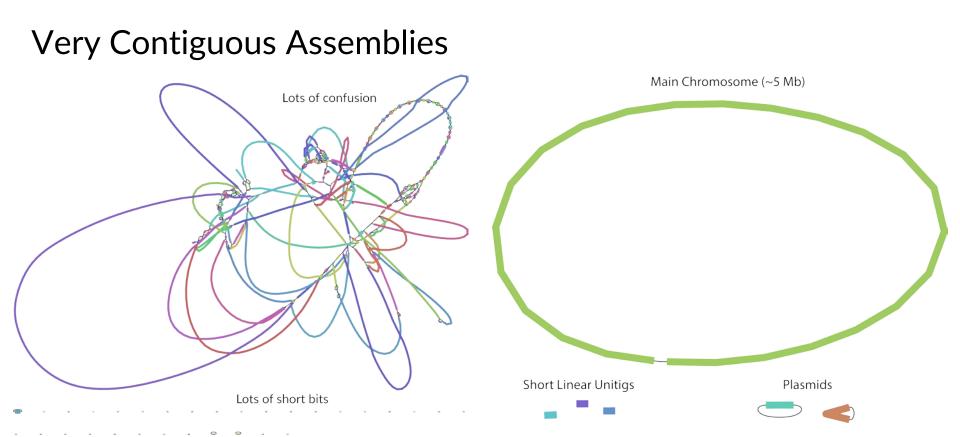


Library prep essentially consists of two ligation steps, so small circular DNA are easily missed.

Shearing (to about 10kb) is necessary to linearize plasmids.







Only Illumina reads

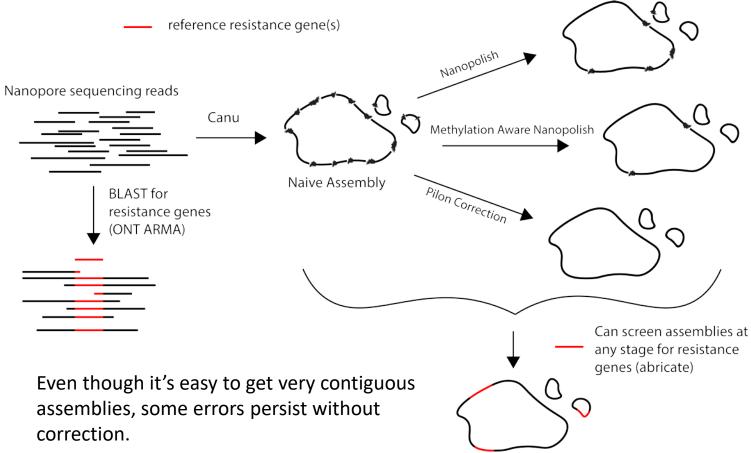


(~200X coverage, v2 150bp PE)

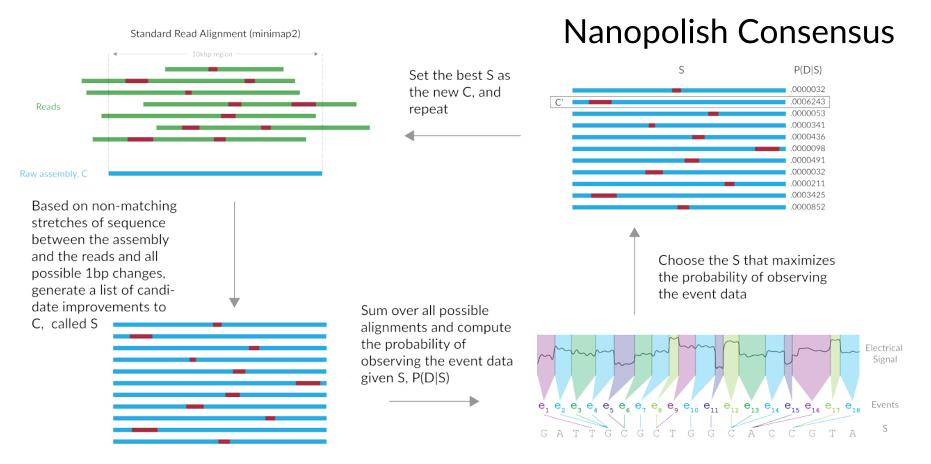
Only Nanopore reads

(~2000X coverage, r9.4 flowcell)

Assembly Pipeline





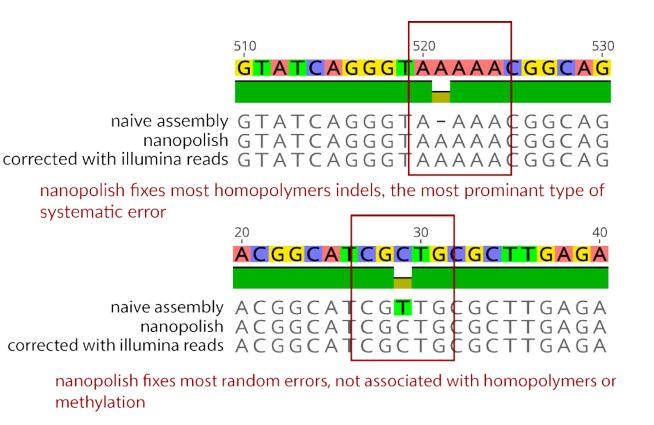


Use raw electrical data to correct assemblies.

Jared Simpson: https://github.com/jts/nanopolish

Nanopolish Consensus

Homopolymers are systematically miscalled on this platform, causing indels and difficulty in determining potential phenotypic consequences.



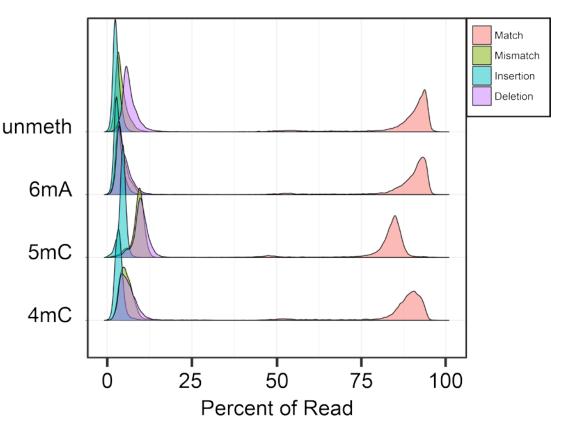


Methylation Associated Error

Because the sequencer physically interrogates DNA molecules, chemical modifications like methyl marks also cause systematic error.

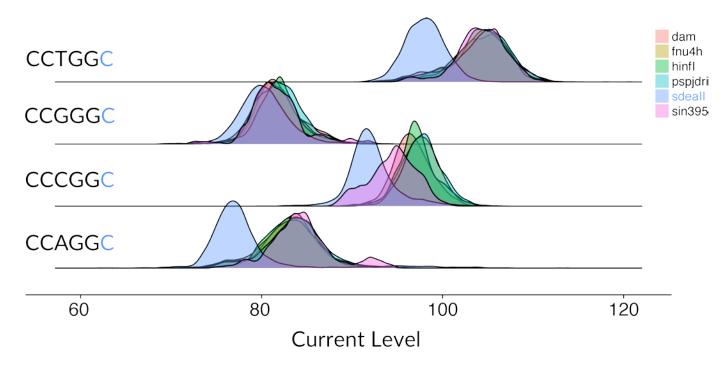
E. coli DNA with controlled methylation types cause an increase in non-matches when reads are aligned to a reference.

DNA samples courtesy of NEB





Methylation Associated Error

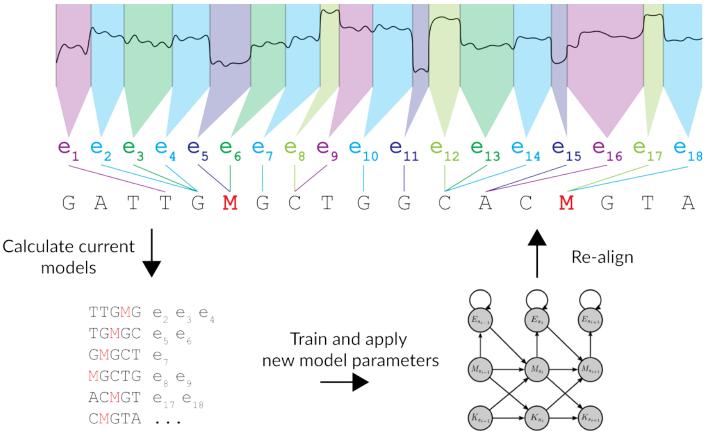


Distinct changes in current distribution at methylation motifs can cause basecalling errors in all the reads, which persist through assembly.



Methylation Associated Error

We can address this problem by training models specifically for methylation motifs, using a similar HMM scheme to align electrical data to a reference.

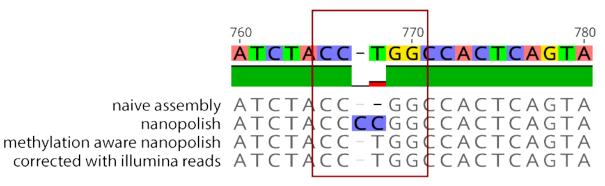




http://simpsonlab.github.io/2017/10/31/methylation-aware/

Methylation Aware Nanopolish

With methylation aware correction, nanopore-only assemblies can achieve in the range of 99.8% identity with assemblies corrected using Illumina reads.



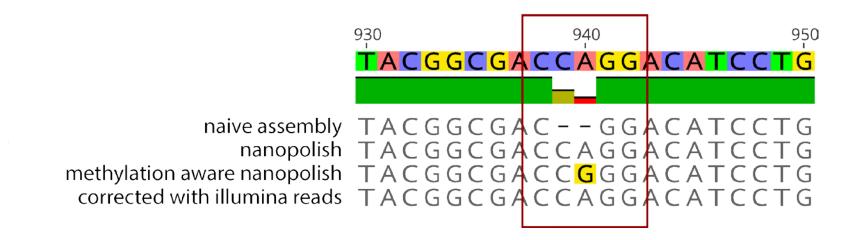
models need to be trained on methylated k-mers in order to correct MTase motifs (dcm MTase= CCWGG)

Raw	Nanopolish	Methylation Aware
Assembly	Corrected	Nanopolish Corrected
98.89%	99.57%	99.76%



http://rebase.neb.com/rebase/rebase.html

Methylation Aware Nanopolish

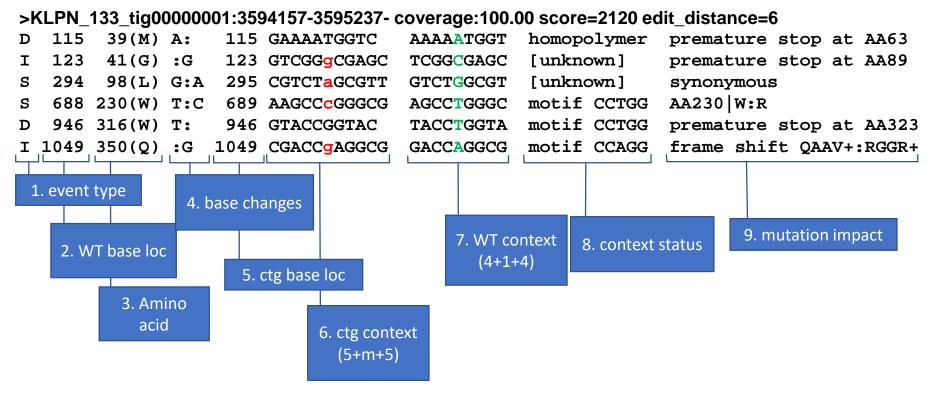


Not a perfect correction scheme yet. We need a more universal training set in order to attempt to address all possible methylation associated errors.

NB: methylation-aware mode is still experimental



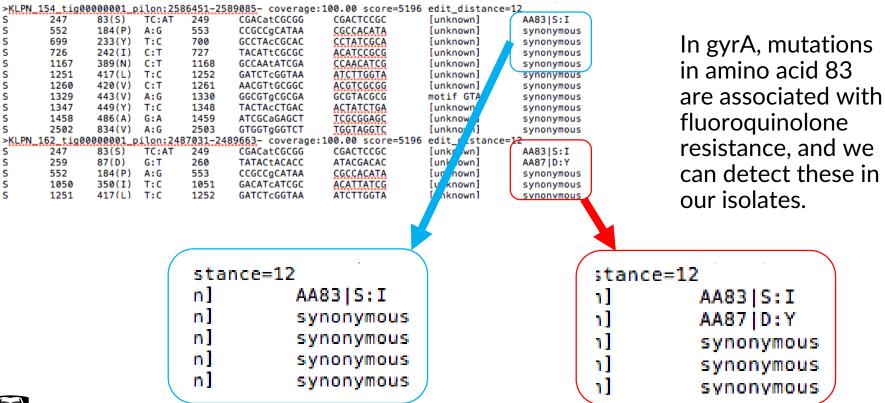
Consequential Mutations





Geo Pertea: https://github.com/gpertea/pwasm (under development)

Consequential Mutations



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Future Directions

Better training for methylation polishing

Local assemblies or alignment consensus to speed up pipeline for point of care use.



Acknowledgements



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